

L Number	Hits	Search Text	DB	Time stamp
1	655	(438/592).CCLS.	USPAT	2002/04/03 10:14
2	125	((438/592).CCLS.) and ((tin (ti titanium) adj nitride) same (w tungsten co cobalt))	USPAT	2002/04/03 10:17
-	9420	(diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)	USPAT	2002/04/02 13:01
-	1720	((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (fsg bpsg psg bsg silicate adj glass\$2 siof)	USPAT	2002/04/02 13:03
-	1790	((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (doped adj (oxide\$1 dioxide\$1))) (((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (fsg bpsg psg bsg silicate adj glass\$2 siof))	USPAT	2002/04/02 13:14
-	1770	((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (doped adj (oxide\$1 dioxide\$1))) (((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (fsg bpsg psg bsg silicate adj glass\$2 siof))) and (temperature\$1 thick\$4 pressure\$1 plasma power rf frequenc\$3) (438/627,628,643,644,653,654).CCLS.	USPAT	2002/04/02 13:20
-	1237	((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (doped adj (oxide\$1 dioxide\$1))) (((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (fsg bpsg psg bsg silicate adj glass\$2 siof))) and (temperature\$1 thick\$4 pressure\$1 plasma power rf frequenc\$3)) and ((438/627,628,643,644,653,654).CCLS.)	USPAT	2002/04/02 13:35
-	262	((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (doped adj (oxide\$1 dioxide\$1))) (((diffusion barrier) same (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion)) and (fsg bpsg psg bsg silicate adj glass\$2 siof))) and (temperature\$1 thick\$4 pressure\$1 plasma power rf frequenc\$3)) and ((438/627,628,643,644,653,654).CCLS.)	USPAT	2002/04/02 17:24
-	7933	((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) and ((doped near3 (oxide\$1 dioxide\$1 glass\$2)) bsg bpsg fsg siof psg)	USPAT	2002/04/02 17:30
-	0	((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) and ((doped near3 (oxide\$1 dioxide\$1 glass\$2)) bsg bpsg fsg siof psg)) and (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) same ((n nitrogen) near2 rich near2 plasma))	USPAT	2002/04/02 17:32
-	104	((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) and ((doped near3 (oxide\$1 dioxide\$1 glass\$2)) bsg bpsg fsg siof psg)) and (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) same ((n nitrogen) near10 plasma))	USPAT	2002/04/02 17:34

-	104	((((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) and ((doped near3 (oxide\$1 dioxide\$1 glass\$2)) bsg bpsg fsg siof psg)) and (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) same ((n nitrogen) near10 plasma))) and (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) same ((n nitrogen) near10 plasma)))	USPAT	2002/04/02 17:50
-	81	((((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) and ((doped near3 (oxide\$1 dioxide\$1 glass\$2)) bsg bpsg fsg siof psg)) and (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) same ((n nitrogen) near10 plasma))) and (((metal\$3 ta ti tantalum titanium tungsten W aluminum al) near3 (nitride\$1 oxy\$lnitride\$1)) tin aln tan tion) same ((n nitrogen) near10 plasma))) and ((temperature pressure thick thickness rf frequenc\$3 power watt\$1) same ((n nitrogen) near10 plasma)))	USPAT	2002/04/02 17:52